

Docket No.: SUT-9004/DIV (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Letters Patent of: Hideo Sugai et al.

Patent No.: 6,744,211

Issued: June 1, 2004

For: PLASMA DENSITY INFORMATION MEASURING METHOD PROBE USED FOR MEASURING PLASMA DENSITY INFORMATION, A PLASMA DENSITY

INFORMATION MEASURING APPARATUS

Certificate NOV 2 2 2004

of Correction

REQUEST FOR CERTIFICATE OF CORRECTION PURSUANT TO 37 CFR 1.323

MS Post Issue Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Upon reviewing the above-identified patent, Patentee noted a typographical error which should be corrected.

In the Second Assignee:

At page 1, please correct the second assignee from Nagoya University to President of Nagoya University.

The error was found in the application as filed by applicant. Please charge our Deposit Account No. 18-0013 in the amount of \$100.00 covering the fee set forth in 37 CFR 1.20(a).

The error now sought to be corrected is an inadvertent typographical error the correction of which does not involve new matter or require reexamination.

11/18/2004 NNGUYEN2 00000152 180013 6744211

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Patent No.: 6,744,211 Docket No.: SUT-9004/DIV

Transmitted herewith is a proposed Certificate of Correction effecting such amendment. Patentee respectfully solicits the granting of the requested Certificate of Correction.

The Director is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 18-0013, under Order No. SUT-9004/DIV. A duplicate copy of this paper is enclosed.

Dated: November 17, 2004

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Respectfully submitted

By David T. Nikaido

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Lee Cheng

Registration No.: 40,949

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PTO/SB/17 (10-04v2) Approved for use through 7/31/2006. OMB 0651-0032

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FEE TRANSMITTAL	ı	Application Number				Patent#: 6,744,211		
for FY 2005	ľ	Filing Date				Issued: June 1, 2004		
	First Named Inventor					Hideo Su	gai	
Effective 10/01/2004. Patent fees are subject to annual revision.		Examiner Name				J. T. Vu		
Applicant claims small entity status. See 37 CFR 1.27	ı	Art Ur	nit			2821		
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1005 160 2005 80 Provisional filing fee	1451	1,510	1451			_	lic use proceeding	
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Independent Claims -** = X = X	1460	130	1460	130	Petitions to	the Commiss	sioner	
Multiple Dependent =	1807	50	1807	50	Processing	fee under 37	CFR 1.17(q)	
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SUBTOTAL (2) (\$) 0.00 **or number previously paid, if greater; For Reissues, see above				100.00				
SUBMITTED BY	(Complete (if englishel))							
Name (Print/Type) David T. Nikaide/Lee-Cheng	Registration No. (Attorney/Agent) 22,663/40,949 Telephone (202) 955-3750							
Signature	Allome	yr Agent)	_1			Date	November 17, 2	2004
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(Also Form PTO-1050)

UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.

6,744,211

DATED

June 1, 2004

INVENTOR(S) :

Hideo Sugai et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Second Assignee:

From "Nagoya University" to -- President of Nagoya University--.

MAILING ADDRESS OF SENDER: David T. Nikaido RADER, FISHMAN & GRAUER PLLC 1233 20th Street, N.W. Suite 501 Washington, DC 20036

PATENT NO. 6,744,211

No. of additional copies 1



(12) United States Patent

Sugai et al.

(10) Patent No.:

US 6,744,211 B2

(45) Date of Patent:

Jun. 1, 2004

(54)	PLASMA DENSITY INFORMATION
` ,	MEASURING METHOD, PROBE USED FOR
	MEASURING PLASMA DENSITY
	INFORMATION, AND PLASMA DENSITY
	INFORMATION MEASURING APPARATUS

Inventors: Hideo Sugai, Kasugai (JP); Seiichi Takasuga, Takarazuka (JP), Naoki

Toyoda, Takarazuka (JP)

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Assignees: Nissin Inc., Hyogo (JP): Nagoya (73)University, Aiti (JP)

Subject to any disclaimer, the term of this (*) Notice: patent is extended or adjusted under 35 U.S.C. 154(b) by 420 days.

Appl. No.: 09/972,944 (21)

(22)Filed: Oct. 10, 2001

(65)**Prior Publication Data**

US 2002/0047543 A1 Apr. 25, 2002

Related U.S. Application Data

Division of application No. 09/357,773, filed on Jul. 21, 1999.

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Н01Ј 7/24	 Int. Cl.7	(51)
	 U.S. Cl.	(52)

(58)315/111.51, 111.71, 111.81, 111.91; 118/723 I, 723 IR, 723 AN; 156/345; 324/576

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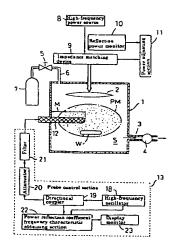
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5,111,111 A 5/1992 Stevens et al. 315/111.41 Primary Examiner—Tuyet Vo Assistant Examiner-Jimmy T. Vu (74) Attorney, Agent, or Firm-Rader, Fishman & Grauer PLLC

(57)**ABSTRACT**

A plasma density information measuring method capable of easily measuring the plasma density information over the long term, a probe for measuring the plasma density information, and a plasma density information measuring apparatus are disclosed. A measuring probe is set such that a tip end of a glass tube of the measuring probe is brought into contact with plasma PM to be measured. Highfrequency power sent through a coaxial cable is supplied to the plasma PM from a loop antenna through a wall of the tube, and reflection power of the high-frequency power is received by the loop antenna to obtain a counter frequency variation of reflection coefficient of the high-frequency power. In the obtained reflection coefficient, a portion thereof in which the reflection coefficient is largely reduced is a peak at which strong absorption of high-frequency power is caused due to the plasma density. The plasma density can be obtained from the plasma absorption frequency.

12 Claims, 14 Drawing Sheets



156/345